

Supporting Information

Enhanced Broadband Photoresponse of a Self-Powered Photodetector Based on Vertically Grown SnS layers via the Pyro-Phototronic Effect

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†Electronic supplementary information (ESI) available

The electrical properties of SnS samples were characterized by a Hall measurement system (Hall measurement system, AHT5573R, Ecopia) using the van der Pauw contact method. The vertically grown SnS layers were investigated by Hall measurement and revealed *p*-type characteristics with an acceptor carrier concentration (N_A) of 10^{17} cm^{-3} and a Hall mobility of $15 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$ at room temperature. More accurate data can be achieved by a field effect transistor to reach the high mobility values of $4200 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$.¹

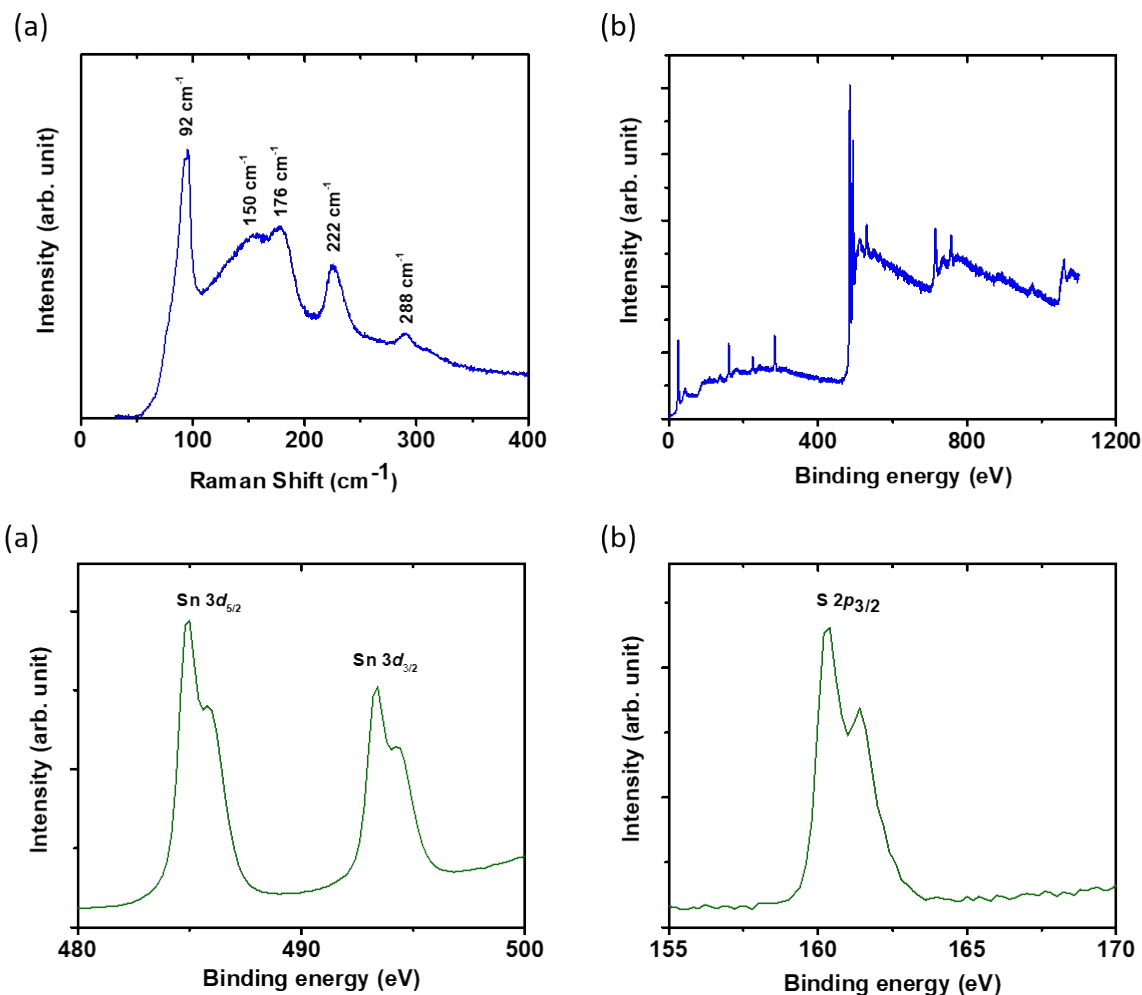


Fig. S1. Elemental analysis. (a) Raman spectra of tin sulphide, examined by spectroscopy (confocal Raman imaging, WITec alpha300) with an excitation wavelength of 532 nm (Laser: helium–neon) with a spatial resolution of $<0.3 \mu\text{m}$ and spectral resolution of $<0.01 \text{ nm}$. X-ray photoelectron spectroscopy. (b) Survey spectra of SnS layers, (c) and (d) represent the XPS peaks of Sn and S, respectively.

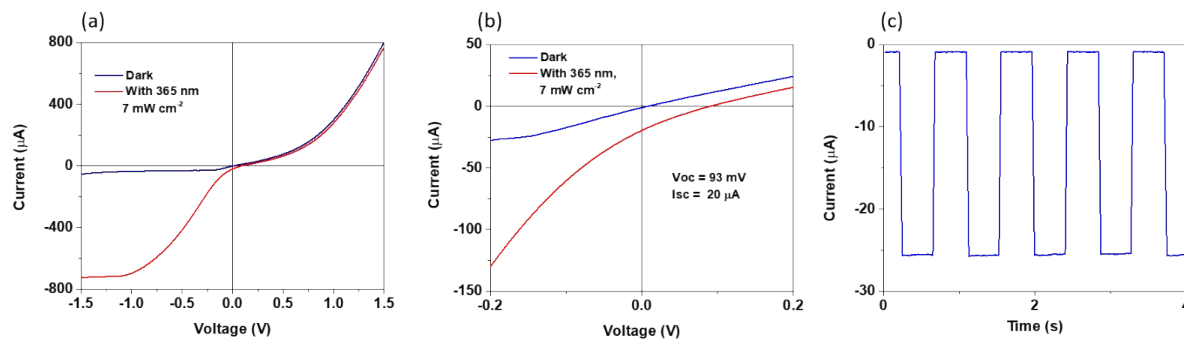


Fig. S2. Charge transport properties of ITO/*n*-Si heterojunction (without SnS layers). (a) Dark and UV current-voltage characteristics, depicting a significant change with light. (b) Shows a magnified view of (a), confirming its self-biased behavior. (c) Current-time behavior of the ITO/Si device under zero bias condition. Absence of peak can be clearly observed. In addition, response does show relatively slow response time in comparison to SnS-based device.

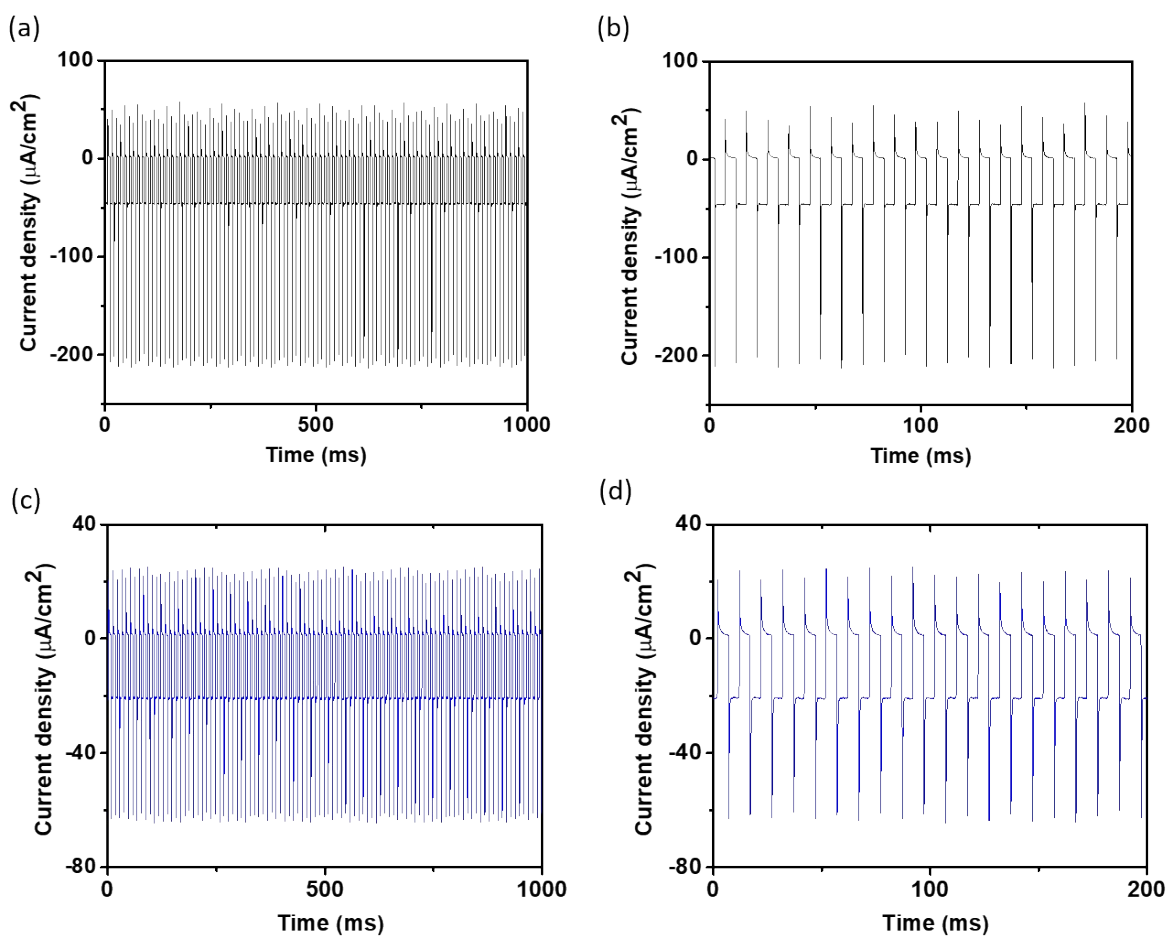


Fig. S3. Stability and durability. (a) Current-time behavior of ITO/SnS/Si/Al device under 660 nm at 3 mW cm^{-2} for 100 cycles, showing high reproducing behavior of the device. A magnified view of the same is depicted in (b). (c) Shows the current-time response of ITO/SnS/Si/Al device under 850 nm at 1 mW cm^{-2} for 100 cycles. A magnified view of the same is depicted in (d). These plots confirm that the presence of pyro-phototronic effect in vertically grown SnS layers is highly reproducible.

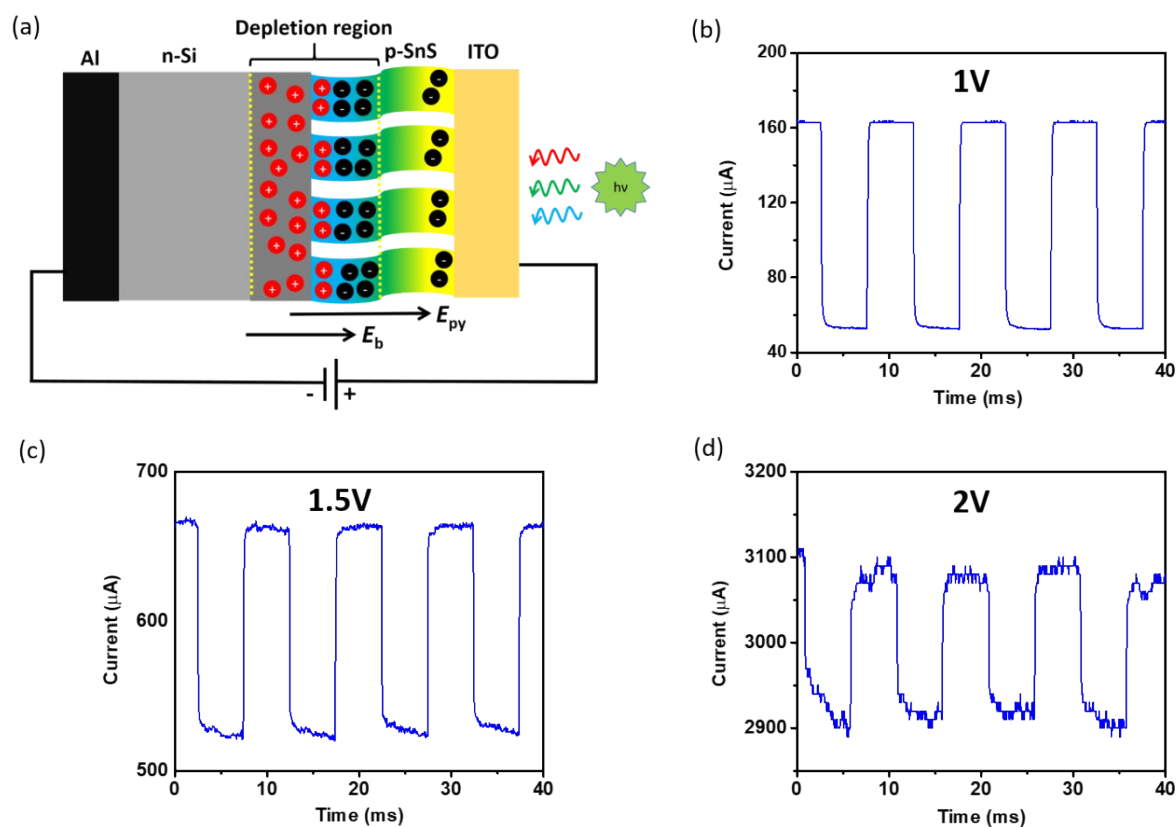


Fig. S4. Collapsing behavior of device. (a) Schematics diagram of ITO/SnS/Si/Al device with an applied external biased. (b) Current-time behavior of the device with applied +1V. Interestingly, no peak was observed, confirming the collapsing nature of the pyro-phototronic effect. (c) and (d) show the current response of the device, confirming that the rise and fall times are increasing with increasing applied external voltage.²

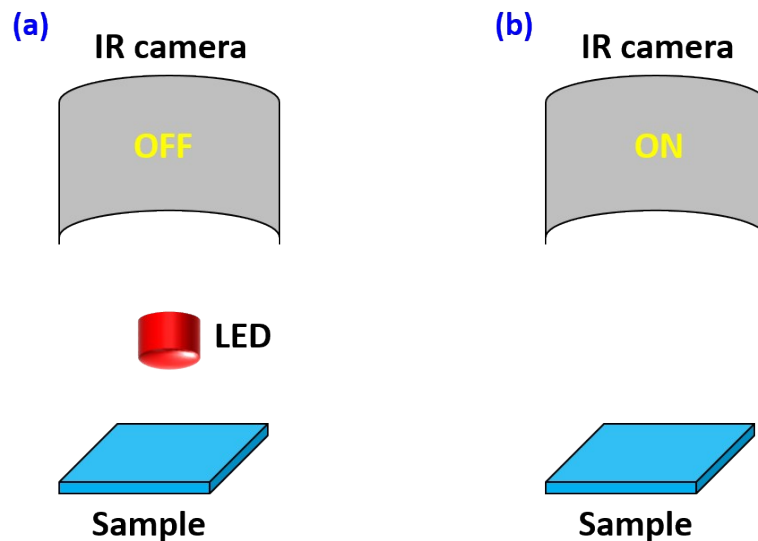


Figure S5: Schematic diagrams for the light-induced pyro-electric potential: (a) LED-induced surface heating and (b) image capturing after removing LED.

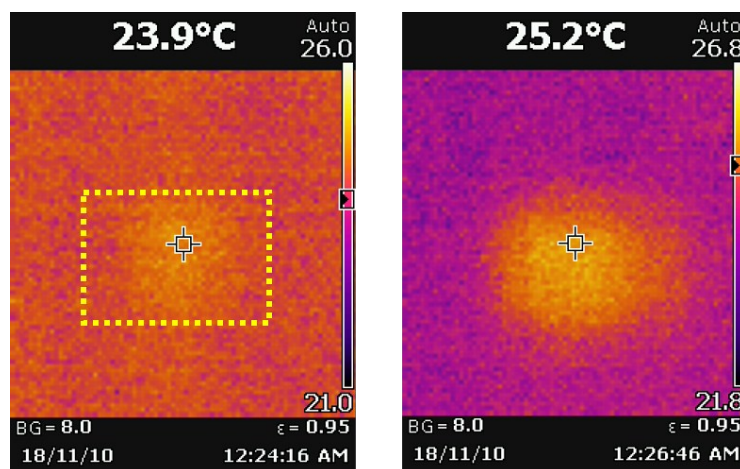


Figure S6: Change in the surface temperature due to pulsed (1k Hz) 650 nm illumination, 7 mW cm^{-2} for different times. To avoid the direct light reflection from the surface, these images are collected after the illumination [dotted yellow line shows the sample size, $1 \times 1 \text{ cm}^2$]. It is also mentioned here that observed nonuniformity of the measurements could be due to used cylindrical LED light source and large area.

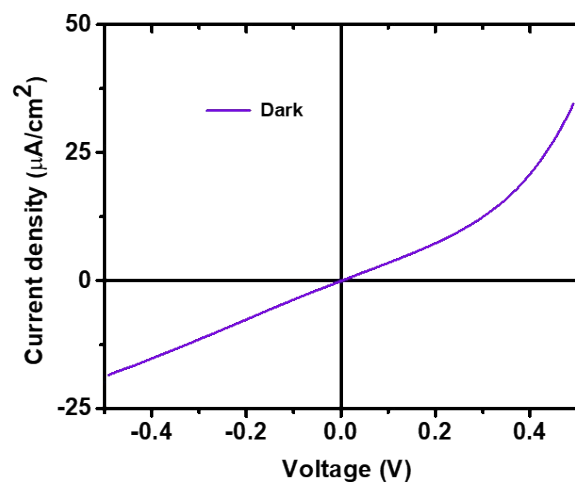


Figure S7: Dark I - V characteristic of SnS/Si junction.

Notes and references

1. M. Patel, H.-S. Kim, and J. Kim, 2017, DOI:10.1039/C7NR03370B.
2. Z. Wang, R. Yu, C. Pan, Z. Li, J. Yang, F. Yi, Z. L. Wang, *Nat. Commun.* 2015, 6, 9401.